

	March 4, SUN	March 5, MON	March 6, TUE	March 7, WED	March 8, THU	
9		Registration	Registration	Registration	Registration	
			J. Musil 1137 [Invited] K. Iga 1176	[Invited] K. Yamamura [Invited] K. Fukuzawa [Invited] M. Gherardi	[Invited] J. W. Bradley [Invited] S. Keller [Invited] J. F. Kolb C. W. Chang 1142 K. C. Peng 1194	
10		Opening Address, Introduction of Plenary Lecture Plenary Lecture S. Iijima (Meijo University, Japan)	Y. Miki 1049 T. Zhang 1197 S. Kaneko 1115 S. Ajia 1011	S. Otake 1043 X. Li 1100 M. Imamura 1133 Y. Pilloux 1104	[Invited] H. Chae J. Kim 1280 Z. Y. Chen 1089 T. Dong 1205 C. F. Hsien1246 C. Y. Wu 1090	[Invited] H. Fukushima 1304 [Invited] H. Tokuda 1110 [Invited] N. Taoka 1247 [Invited] M. Takeno 1154 [Invited] C. L. Castro 1075 [Invited] K. Takaki 1079 T. Xie 1106 V. Svrcek 1152 K. Koga 1155 H. Nakamura 1121
11		Keynote Lecture J. G. Han (Sungkyunkwan University, Korea)	Poster Session 2 (1.5h)		Poster Session 3 (1.5 h)	
12		Keynote Lecture U. Czarnetzki (Ruhr-Universität Bochum, Germany)	Lunch Break (1.5h)		Lunch Break (1.5h)	
13	Registration Plasma Science & Technologies Tutorial (1h) P. Chabert (LPP, CNRS, Ecole Polytechnique, France)	Lunch Break (1.5h)	Lunch Break (1.5h)	Lunch Break (1.5h)	Award, Closing Remarks	
14	Nitride Semiconductors Tutorial (1h) Y. Nanishi (Ritsumeikan University, Japan)	[Invited] D. Rafalsky H. Himura 1063 M. Hotta 1114 T. T. Nguyen 1099 H. Suzuki 1190	[Invited] S. Krukowski T. Hattori 1305 Y. Isobe 1014 F. B. Abas 1008 A. Tanide 1007	[Invited] G. Dinescu M. Nagatsu [Invited] Y. Nakatsu K. Nagashio C. H. Yang 1045 C. K. Chiang 1258	[Invited] W. H. Chiang D. Feezel T. C. Wei E. Martines M. Takahashi 1050 Muranaga 1208 X. Zhao 1177 S. Muneekaew 1244 Y. Sato 1301 Khan 1237 D. Ogawa 1268 Y. J. Cheng 1029 R. Borude 1269 H. Tanaka 1085 Y. Hosoi 1016	
15	Nanomaterials Tutorial (1h) Y. Saito (Nagoya University, Japan)	[Invited] J. P. Trelles N. Tansu	[Invited] K. Matsuda H. Kano	Plenary Lecture I. Akasaki (Meijo University, Japan)		
16	Bio applications Tutorial (1h) P. Favia (University of Bari, Italy) H. Sakakita (AIST, Japan)	[Invited] S. Gortchakow Y. Tanaka 1130	A. Kusaba 1162 Y. Inaishi 1033 T. Okada 1153 K. Nakazato Y. Huang 1224	Topical Session GaN plasma process		
17		Poster Session 1 (1.5h)		Topical Session 2-1: S. Chowdhury		
18	Welcome Party(1.5h)	Banquet (2h) MU garden		Topical Session 2-2: K. Nojiri		
19				Topical Session 2-3: H. Watanabe		
				Topical Session 2-4: R. A. Ferreyra		
				Topical Session 1-1: A. Fridman (Drexel University, U.S.A)		
				Topical Session 1-2: R. Weltmann (INP Greifswald e.V., Germany )		
				Topical Session 1-3: K. Niitsu (Nagoya University, Japan)		
				Topical Session 1-4: Z. Machala(Comenius University, Slovakia)		
				Topical Session 1-5: S. Reuter(Princeton University, USA, INP Greifswald e.V., Germany)		
				Topical Session 3-1: C. H. Wang		
				Topical Session 3-2: T. Nozaki		
				Topical Session 3-3: M. Shiratani		
				Topical Session 3-4: T. Sugaya		
				Topical Session Energy nanomaterial		